

Electronic Patent Application Fee Transmittal

Application Number:	10759671			
Filing Date:	16-Jan-2004			
Title of Invention:	DUAL STEP SOURCE/DRAIN EXTENSION JUNCTION ANNEAL TO REDUCE THE JUNCTION DEPTH: MULTIPLE-PULSE LOW ENERGY LASER ANNEAL COUPLED WITH RAPID THERMAL ANNEAL			
First Named Inventor:	Chyiu Hyia Poon			
Filer:	Mikio Ishimaru/Vickie Ishimaru			
Attorney Docket Number:	CS03-015			
Filed as Large Entity				
Utility Filing Fees				
Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Basic Filing:				
Pages:				
Claims:				
Miscellaneous-Filing:				
Petition:				
Patent-Appeals-and-Interference:				
Post-Allowance-and-Post-Issuance:				
Utility Appl issue fee	1501	1	1400	1400
Publ. Fee- early, voluntary, or normal	1504	1	300	300

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
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Total in USD (\$)				1700